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## **Supplementary Information**

## Dramatically promoted crystallization control of organolead triiodide perovskite film by

## a homogeneous cap for high efficiency planar-heterojunction solar cells

Weidong Zhu, ab Chunxiong Bao, ab Bihu Lv, a Faming Li, ab Yong Yi, ab Yangrunqian Wang, ab

Jie Yang, ab Xiaoyong Wang, a Tao Yu, \*abcd and Zhigang Zouabcd

<sup>a</sup>National Laboratory of Solid State Microstructures, Nanjing University, Nanjing 210093, P. R. China. Email: yutao@nju.edu.cn

<sup>b</sup>Eco-Materials and Renewable Energy Research Center (ERERC) at Department of Physics, Nanjing

University, Nanjing 210093, P. R. China.

<sup>c</sup>Collaborative Innovation Center of Advanced Microstructures, Nanjing University, Nanjing 210093, P. R. China.

<sup>d</sup>Jiangsu Key Laboratory for Nano Technology, Nanjing 210093, P. R. China.



**Fig. S1** Schematically illustrating the experimental processes for preparing precursor OTP film via antisolvent assisted one-step spin-coating route reported by Park et al.<sup>1</sup>.



**Fig. S2** Top-view SEM images used for the statistics of the grain size distribution of (a) HCM crystallized OTP film and (b) control sample obtained by conventional crystallization, respectively. (c) The corresponding histograms of statistic grain size distribution. (d) and (e) The corresponding AFM topographical images with the scanning area of  $5 \times 5 \ \mu m^2$ .



**Fig. S3** Normalized intensity XRD spectra of HCM crystallized OTP film and control sample obtained by conventional crystallization. The solid diamond symbols correspond to the signals from  $TiO_2/FTO$  substrate. The insert gives the peak intensity ratios for (110) to (310) planes and (220) to (310) planes.



**Fig. S4** Low-resolution XPS survey spectra of HCM crystallized OTP film and control sample obtained by conventional crystallization, respectively.



Fig. S5 XRD spectra of HCM crystallized OTP film and control sample obtained by conventional crystallization with the thermal annealing temperature and time to be 150 °C and 40 min. The solid diamond symbols signify the diffraction peaks of OTP with the solid star symbol denoting the diffraction peak of PbI<sub>2</sub> and the hollow diamond symbol denoting the signals of  $TiO_2/FTO$  substrate.



**Fig. S6** (a-d) Top-view SEM images of the different caps of (a) two-step spin-coating deposited OTP film with  $CH_3NH_3I$  concentration of 7.5 mg mL<sup>-1</sup>, (b) two-step spin-coating deposited OTP film with  $CH_3NH_3I$  concentration of 10.0 mg mL<sup>-1</sup>, (c) one-step deposited OTP film prepared by conventional crystallization, and (d) compact TiO<sub>2</sub>.



**Fig. S7** Top-view SEM images used for the statistic of grain size distribution of HCM crystallized OTP films with different caps of (a) two-step deposited OTP film with  $CH_3NH_3I$  concentration of 7.5 mg/mL, (b) two-step deposited OTP film with  $CH_3NH_3I$  concentration of 10.0 mg/mL, (c) one-step deposited OTP film obtained by conventional crystallization, and (d) compact  $TiO_2$ , respectively. The insert gives the corresponding histogram of statistic grain size distribution.



Fig. S8 FTIR spectra of the precursor film and HCM crystallized OTP film, respectively.



Fig. S9 Optical images of droplet of DMSO (a) before and (b) after dropping on the compact  $TiO_2/FTO$  substrate. The rapid spreading of DMSO droplet on compact  $TiO_2$  indicates the super-wetting property of DMSO on compact  $TiO_2$ .



**Fig. S10** (a) Transmission spectra and (b) reflection spectra of HCM crystallized OTP film and control sample obtained by conventional crystallization.



**Fig. S11** Statistic FFs of 20 cells with control samples obtained by conventional crystallization (Conventional crystallization) and HCM crystallized OTP films (HCM crystallization), respectively.

## References

1. N. Ahn, D.-Y. Son, I.-H. Jang, S. M. Kang, M. Choi and N.-G. Park, J. Am. Chem. Soc., 2015, 137, 8696-8699.